

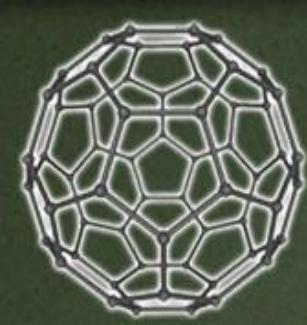
# Optically Induced Capacitance Changes in Organic Semiconductor Based Structures

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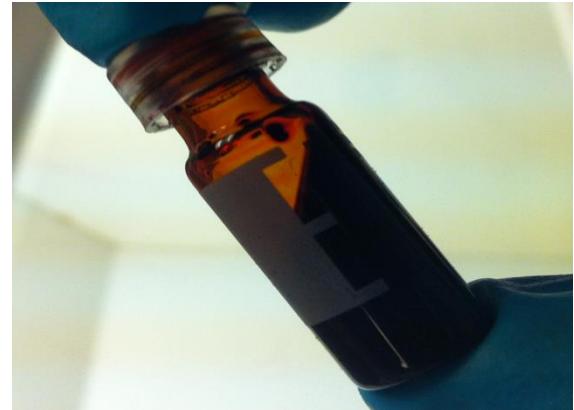
# Contents

- Brief introduction to organic electronics
- Dielectric constant change  $\Delta\epsilon_{Theory} \Rightarrow \Delta\epsilon_{Plasma} = \Delta\epsilon_{(\mu,\Delta n)}$ 
  - Time of Flight  $\Rightarrow \Delta\epsilon_{Spacecharge} = \Delta\epsilon_{(\mu,G)}$
  - Steady State Photocurrent  $\Rightarrow \Delta\epsilon_{e-h} = \Delta\epsilon_{(r_c,\Delta n)}$
- $\Delta\epsilon_{Experimental} = \Delta\epsilon_{(v)}$ 
  - Impedance Spectroscopy
  - GHz - Quasi-Optical Free Space propagation
- $\Delta\epsilon_{Theory}$  vs  $\Delta\epsilon_{Experimental}$
- Conclusions

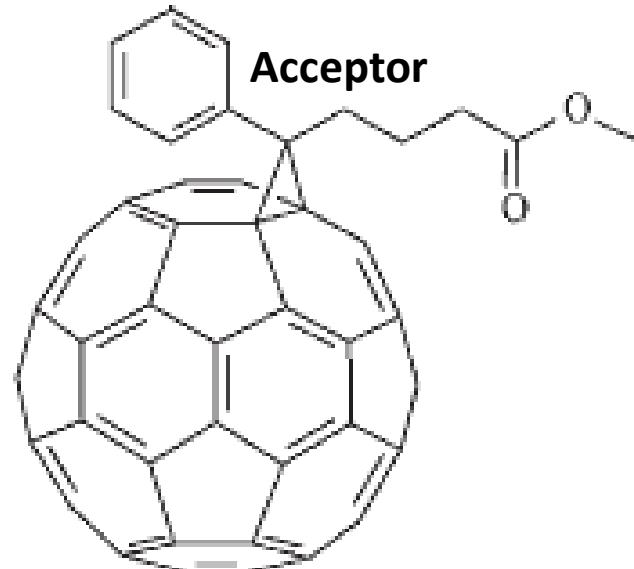
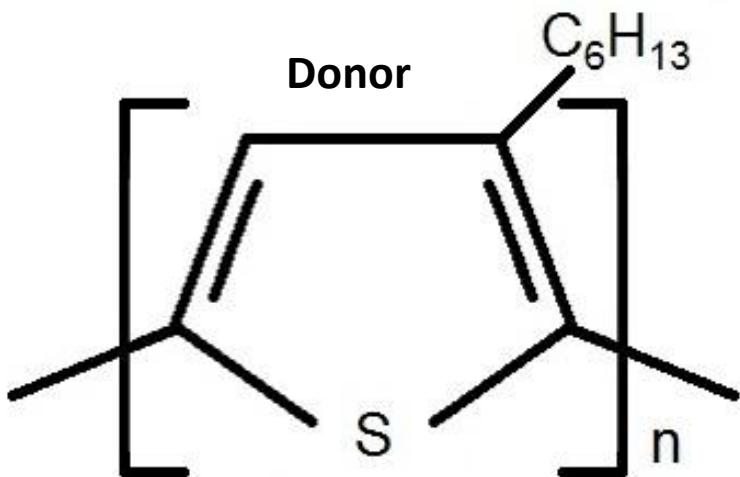


# Organic Materials

- Two semi-conducting organic materials used,
- P3HT and PCBM mixed in a 95:5 ratio respectively.
- When excited, one material donates an electron while the other accepts an electron.



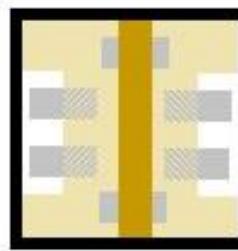
95:5 P3HT:PCBM Mixture



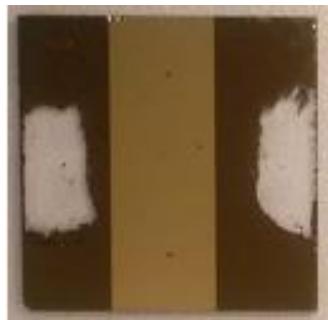


# Organic Electronics

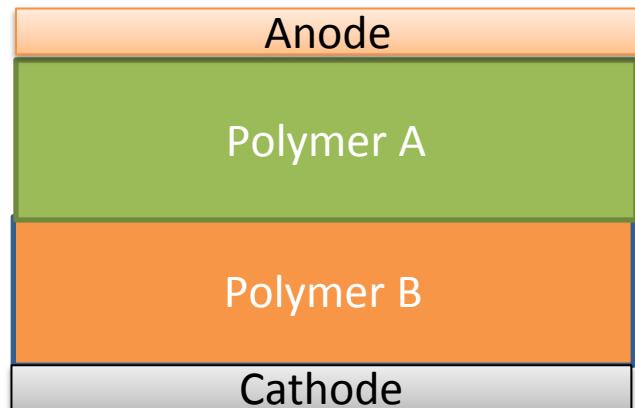
- The polymers are in contact with each other in a junction and in contact to electrodes
- Best way to achieve this is with a Bulk-Heterojunction which maximises dissociation at interface
- Device: ITO:P3HT:PCBM:Al



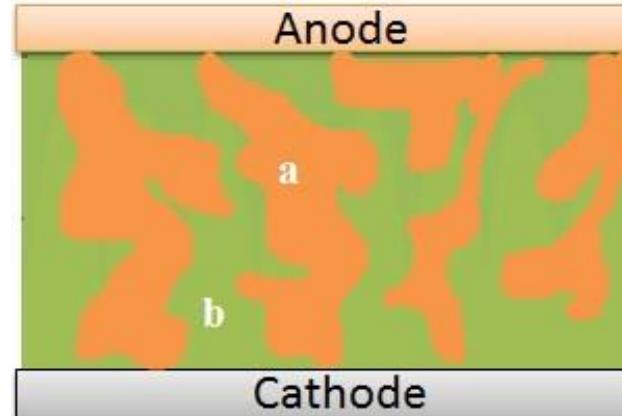
ITO  
Organic Layer  
Gold



95:5 P3HT:PCBM device layout showing the layers of deposited material, the design and the finished device.



A simple bi-layer design



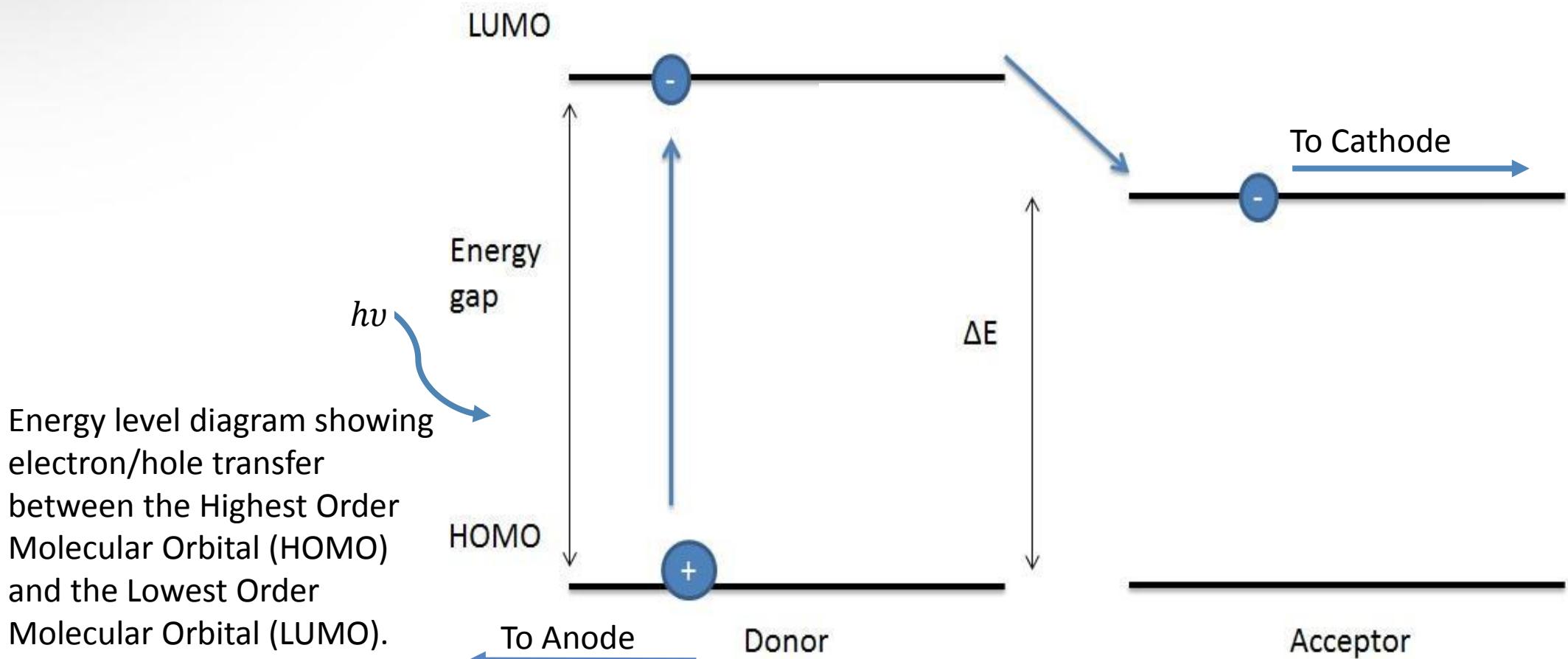
A Bulk-Heterojunction





# Organic Charge Transfer

- LUMO P3HT = 3.7eV
- LUMO PCBM = 3.0eV

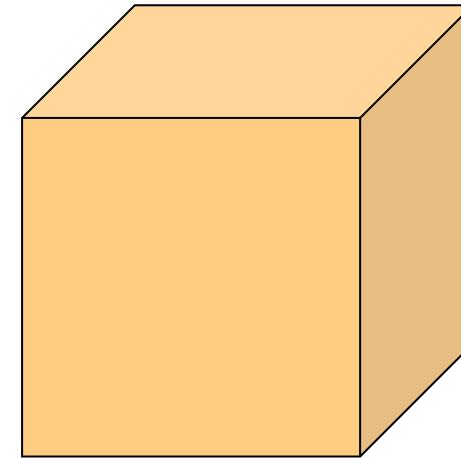




# Dielectric Constant

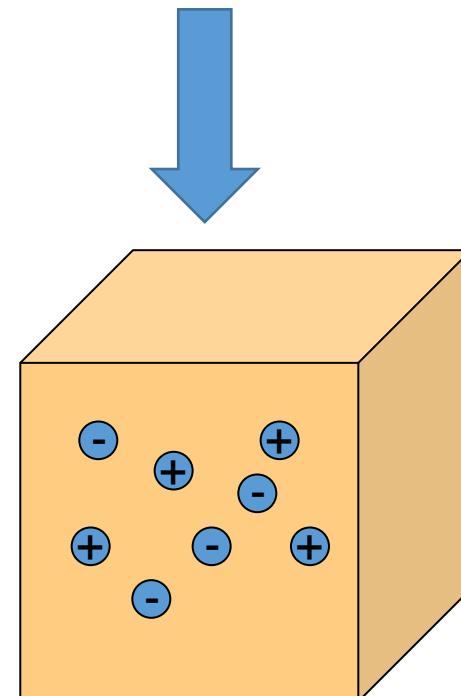
- A slab of conjugated polymer will have some dielectric properties:

$$\epsilon = \epsilon_{dark}$$



- A slab of conjugated polymer under illumination will have different dielectric properties:

$$\epsilon_{illuminated} = \epsilon_{dark} + \Delta\epsilon$$

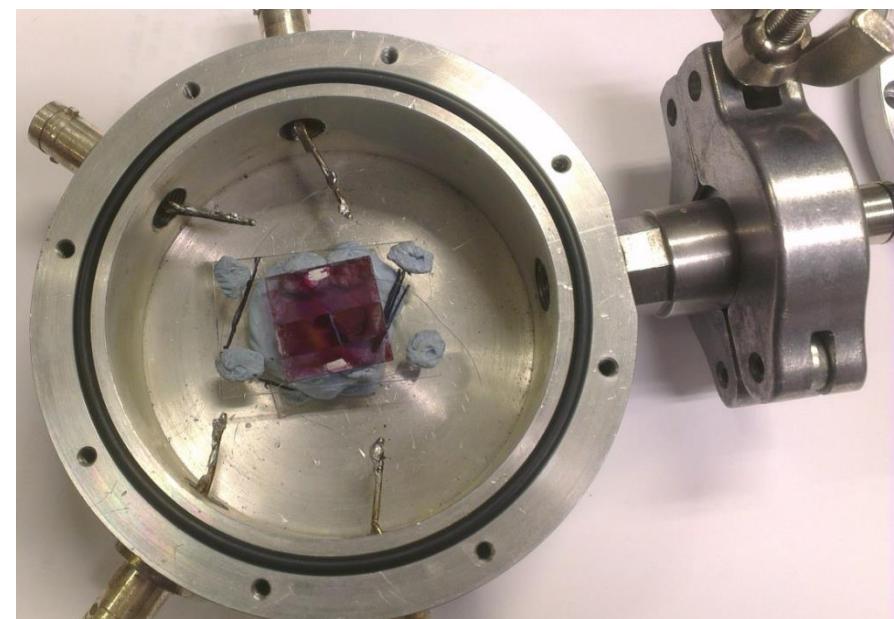




# $\Delta\epsilon$

- Three different theoretical approaches:
- $\Delta\epsilon_{Theory} \Rightarrow \Delta\epsilon_{Plasma} = \Delta\epsilon_{(\mu, \Delta n)}$
- $\Rightarrow \Delta\epsilon_{Spacecharge} = \Delta\epsilon_{(\mu, G)}$
- $\Rightarrow \Delta\epsilon_{e-h} = \Delta\epsilon_{(r_c, \Delta n_{e-h})}$
- $\Delta\epsilon_{Experimental} \Rightarrow \Delta\epsilon_{(v)}$  (DC and GHZ)

P3HT:PCBM  
device in an open  
vacuum chamber





$$\Delta\epsilon_{Theory} \Rightarrow \Delta\epsilon_{Plasma} = \Delta\epsilon_{(\mu, \Delta n)}$$

- Change in dielectric constant can be calculated according to established plasma theory: (for high mobility silicon)

$$\Delta\epsilon_{Plasma} = -(m_e \mu_e^2 + m_h \mu_h^2) \frac{\Delta n}{\epsilon_0} \in \mathbb{R}$$

Dielectric Constant Change      Electron/Hole Mobility      Charge Carrier Density

- $\Delta\epsilon_{Plasma}$  is dependant on the density and mobility of the charge carriers
- These can be easily measured, thus  $\Delta\epsilon_{Plasma}$  can be calculated.

$$\begin{aligned}\Delta\epsilon_{Plasma} &\Rightarrow \mu = 10^{-4} \text{cm}^2 \text{V}^{-1} \text{s}^{-1} \\ &\Rightarrow \Delta n\end{aligned}$$



# Charge Carrier Concentration, $\Delta n$

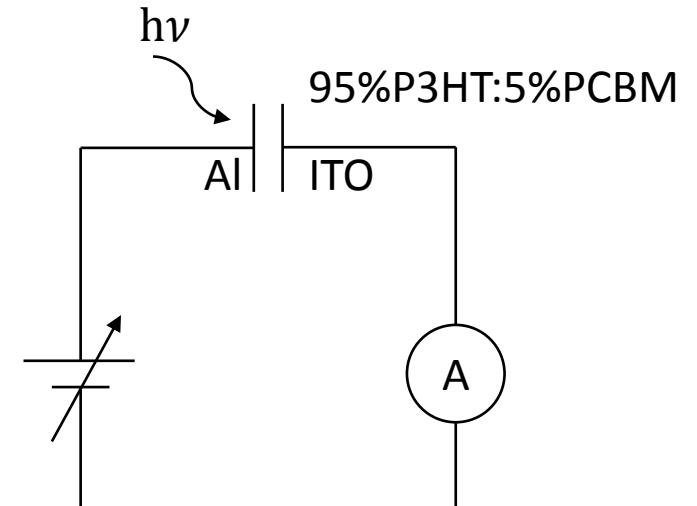
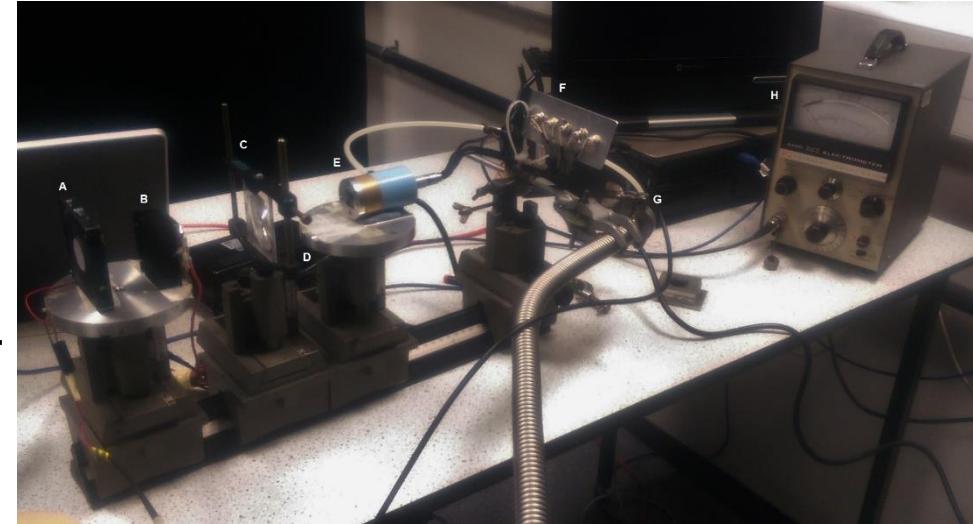
- From Ohms Law:  $J = \Delta n e \mu E$
- And Charge definition between two plates:

$$E = \frac{\Delta\phi}{d} = \frac{V_{eff}}{d} = \frac{V_{Bias} - V_{Built-IN}}{d}$$

- We get  $\Delta n$  as a function of photocurrent, mobility and voltage:

$$\Delta n = \frac{Id}{Ae\mu V_{eff}}$$

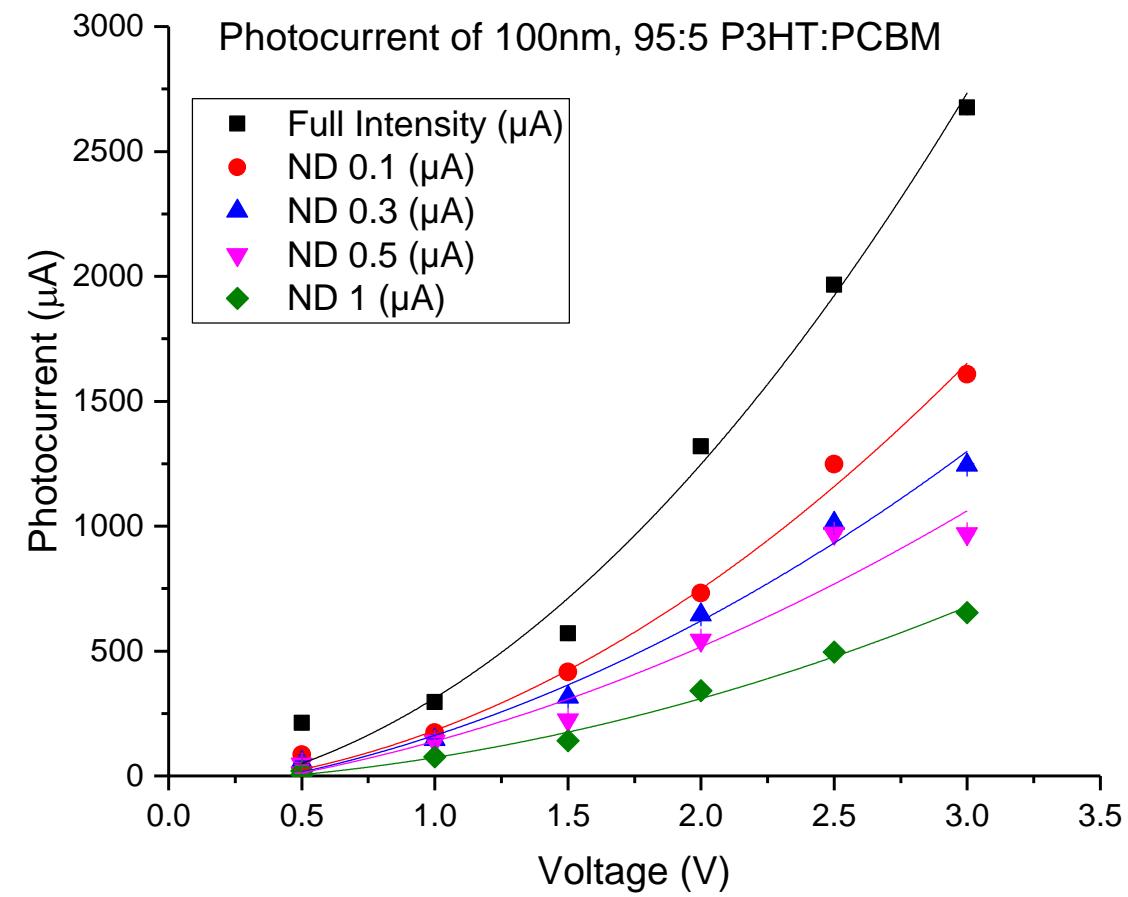
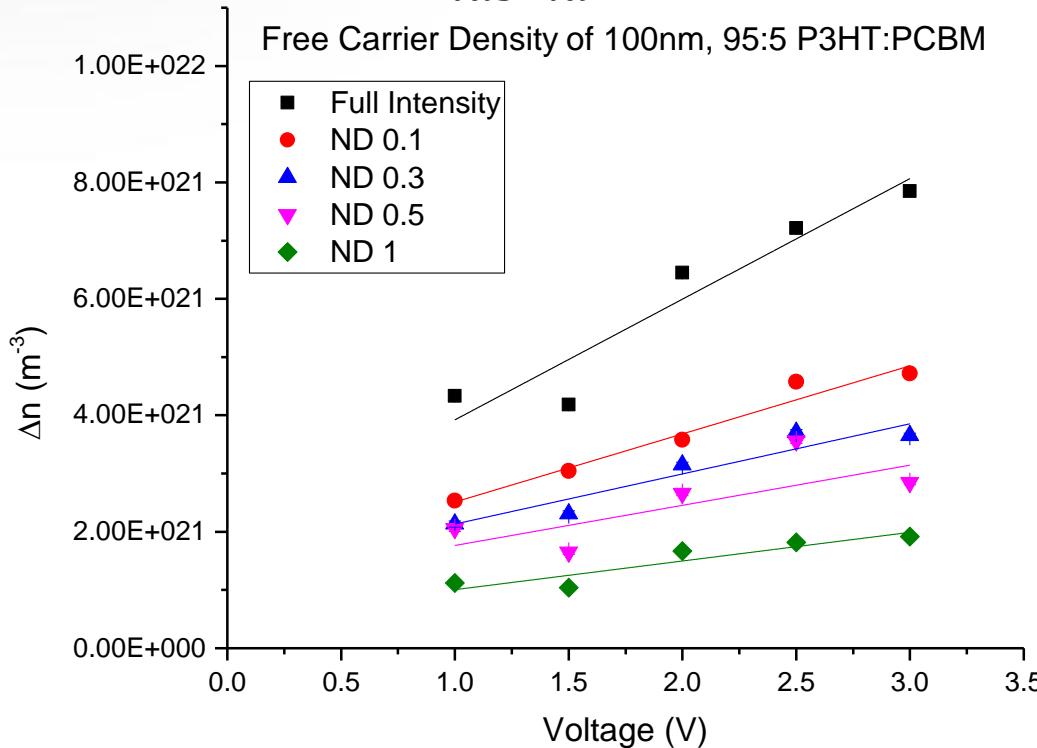
- So simply excite and measure photocurrent under a bias voltage.





# Charge Carrier Concentration, $\Delta n$

- Measure photocurrent
- Calculate  $\Delta n$
- Extrapolate to Zero Field,  $\Delta n_{E=0}$
- Calculate  $\Delta \epsilon_{Plasma}$

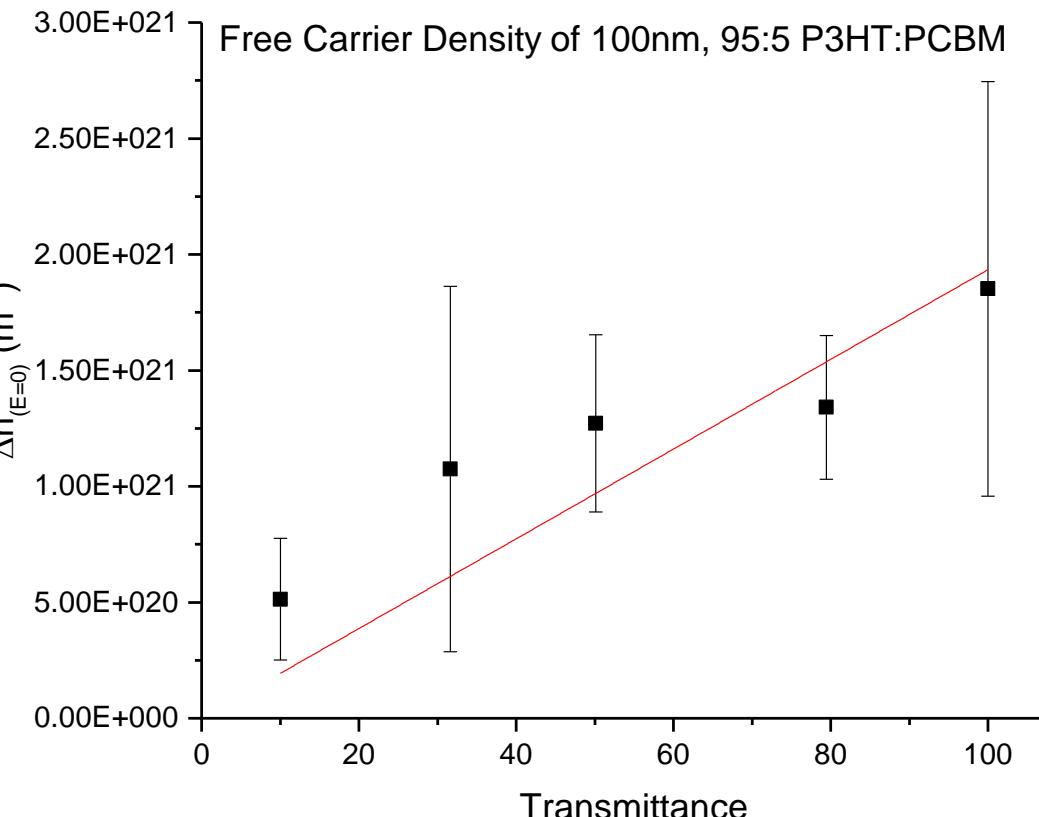
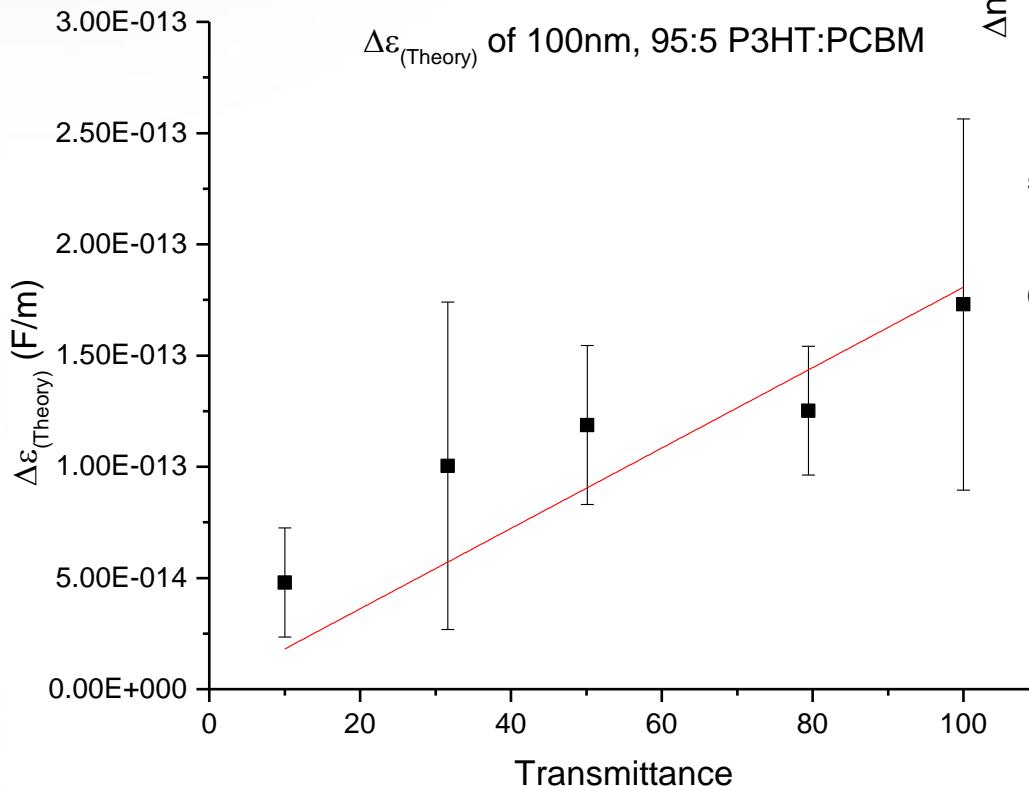


Graphs showing Photocurrent  $I$  (above)  
(quadratic as both  $V$  and  $\mu$  dependant)  
and charge carrier concentration  $\Delta n$  (left)  
against effective voltage  $V_{eff}$ .



# Charge Carrier Concentration, $\Delta n$

- Measure photocurrent
- Calculate  $\Delta n$
- Extrapolate to Zero Field,  $\Delta n_{E=0}$
- Calculate  $\Delta\epsilon_{Plasma}$



Graphs showing zero field concentration  $\Delta n_{E=0}$  (above) and change in dielectric constant  $\Delta\epsilon_{Theory}$  (left) against % light transmittance.  
(100% = 1234 Wm<sup>-2</sup>)

$$\Delta\epsilon_{Theory} \Rightarrow \Delta\epsilon_{Spacecharge} = \Delta\epsilon_{(\mu,G)}$$

- Can model photocapacitance as a spacecharge:

$$C_p = \left( \frac{eGd}{2E_0^2} \right) \left( \frac{1}{(\mu_n + \mu_p)} \right)$$

- Dependant on conductance  $G$  and mobility  $\mu$
- As  $c = \frac{\epsilon\epsilon_0 A}{d}$  and  $E_0 = \frac{V}{d}$
- $c \propto d^3$   $c \approx 10^{-38} F$
- $\Delta\epsilon_{Space Charges} = \Delta\epsilon_{(\mu,G)} = 10^{-26}$

Richard S.  
Crandall,  
Journal of  
Applied  
Physics 54 (12),  
7176 (1983).



$$\Delta\epsilon_{Theory} \Rightarrow \Delta\epsilon_{e-h} = \Delta\epsilon_{(r_c, \Delta n_{e-h})}$$

- $\Delta\epsilon = \Delta\epsilon_{static\ charges} + \Delta\epsilon_{free\ charges}$

Coulombically bound e-h pairs

- rotating with the electronic field
- Traditionally assumed to be negligible
- Derived via:
  - Richard Friend
  - New QMUL Model

Free electrons and holes

- $\Delta\epsilon_{Plasma}$
- $\Delta\epsilon_{Spacecharge}$



$$\Delta\epsilon_{Theory} \Rightarrow \Delta\epsilon_{e-h} = \Delta\epsilon_{(r_c, \Delta n_{e-h})}$$

$$\Delta\epsilon_{static\ charges} = ?$$

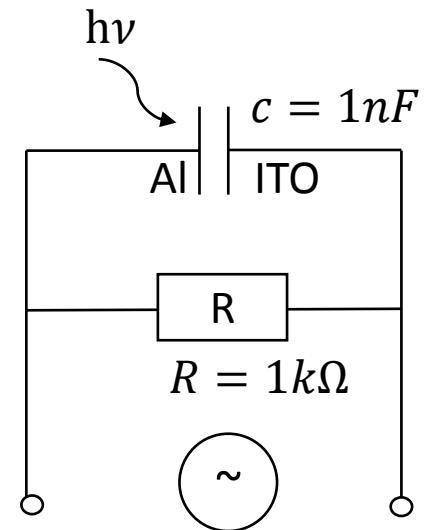
- Can define polarizability per unit dipole as:
    - $\Delta P = \epsilon_0(\Delta\epsilon - 1)E$
    - $\Delta P = \bar{p}_\parallel \Delta n$
  - Dipole moment parallel to Field:
    - $\bar{p}_\parallel \leq p_{e-h} \leq er_c$
  - e-h pair density:
    - $\Delta n_{e-h} \geq \frac{\epsilon_0(\Delta\epsilon-1)E}{er_c}$
    - Using  $\Delta\epsilon$  of order unity
    - $\Delta n_{e-h} \geq 10^{22} \text{ m}^{-3}$
    - which is smaller than the maximum pair density of  $10^{24} \text{ m}^{-3}$
- Assuming a cube of coulomb radius completely filled with *e-h* dipoles:
- $\Delta\epsilon_{e-h} \leq \frac{er_c \Delta n_{e-h} V}{d}$
  - $\Delta\epsilon_{e-h} \leq 10^5$

A. D.  
Chepelianskii,  
J. Wang, and  
R. H. Friend,  
Phys Rev Lett  
112 (12),  
126802 (2014).



# $\Delta\epsilon_{Experimental} = \Delta\epsilon(v)$

- From capacitance definition:  $C = \frac{\epsilon\epsilon_0 A}{d}$
- And RC circuits:  $\omega_{Resonant} = \frac{1}{RC}$
- We get:  $\frac{\Delta\epsilon}{\epsilon} = \frac{\Delta\nu}{\nu}$
- Any change in  $\nu$  comes from change in C from change in  $\epsilon$
- Measurable via Impedance Spectroscopy.
- $\Delta\nu = \Delta\nu_{Light} - \Delta\nu_{Dark}$



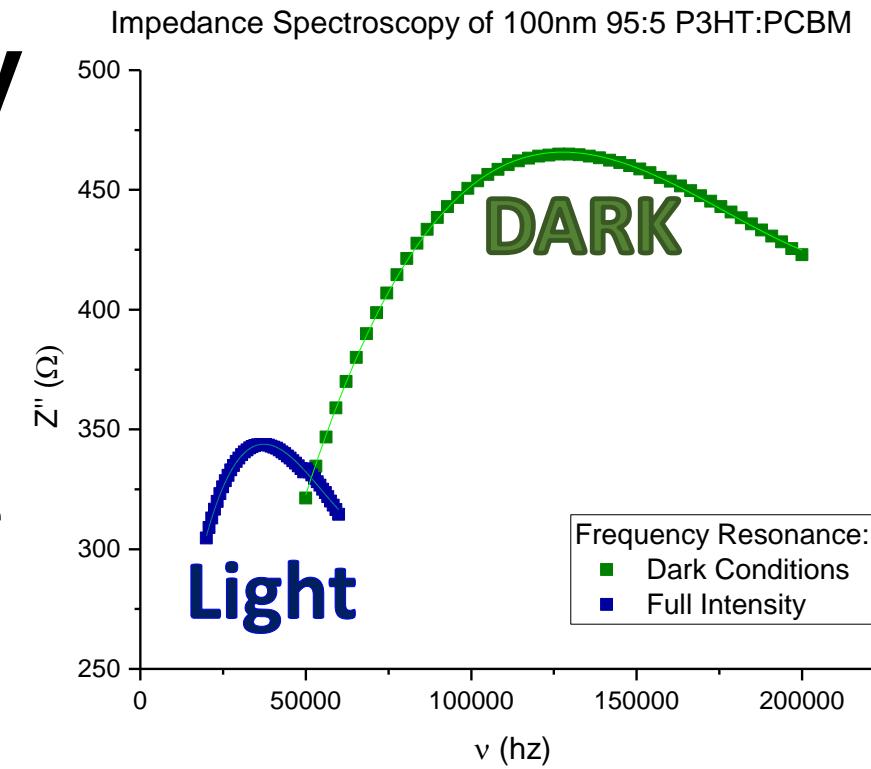
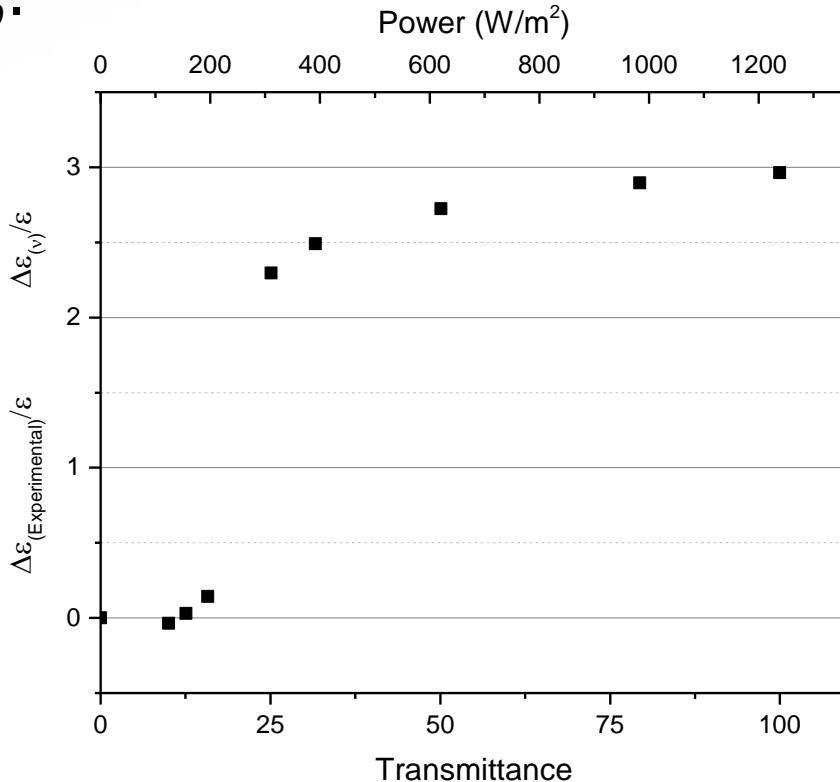
Impedance Spectrometer





# Impedance Spectroscopy

- Sweeps over a range of frequencies
- Finds Imaginary Impedance  $Z'' = \frac{1}{c\omega i}$  as a function of frequency.
- Can find resonance frequency and hence  $\Delta\epsilon_{Exp}$ .



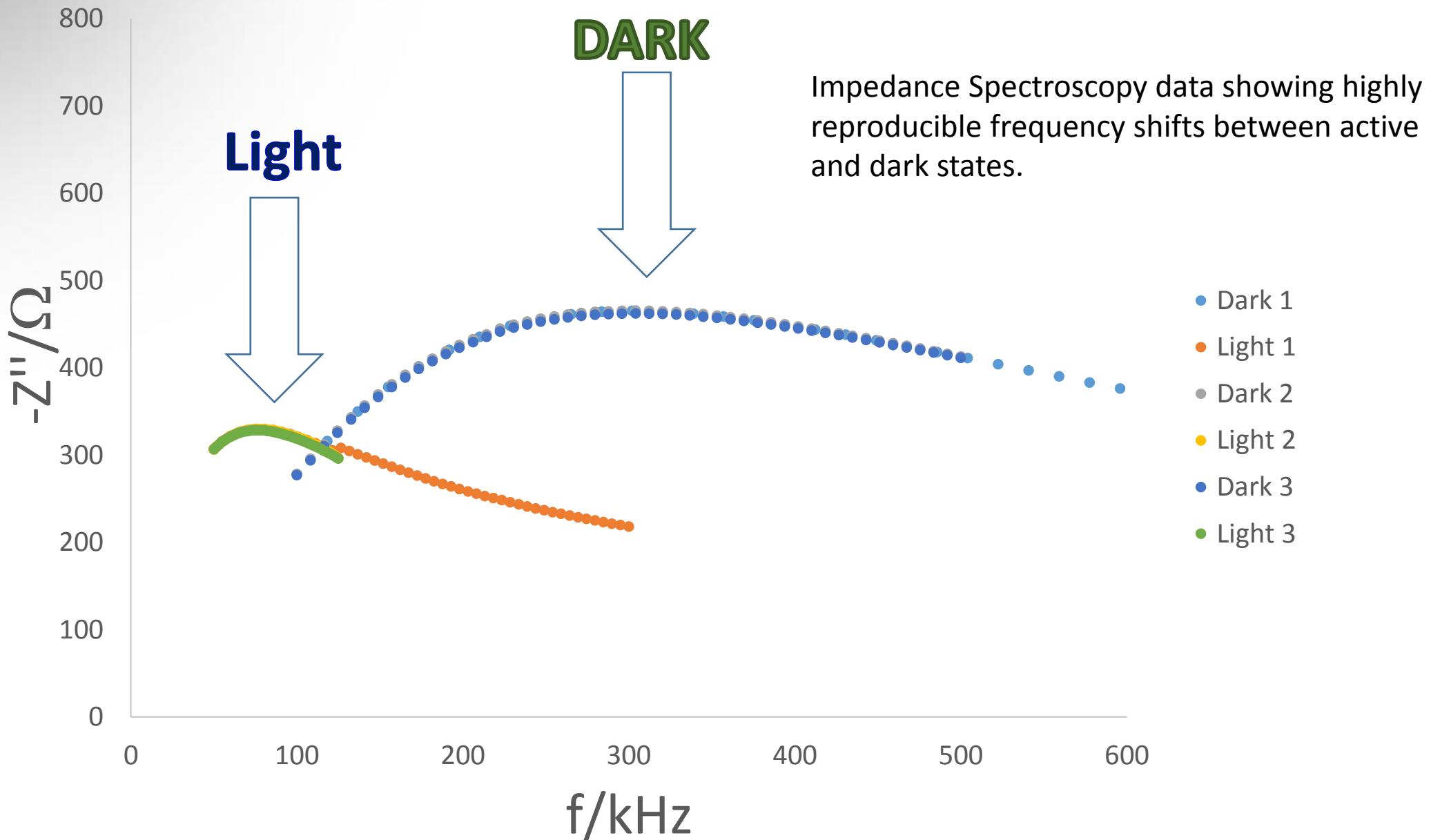
Impedance Spectroscopy data showing highly reproducible frequency shifts between active and dark states.

$\Delta\epsilon_{Exp}$  vs % of light (100% = 1234Wm<sup>-2</sup>)

$\Delta\epsilon = 0.1$  (unsaturated)



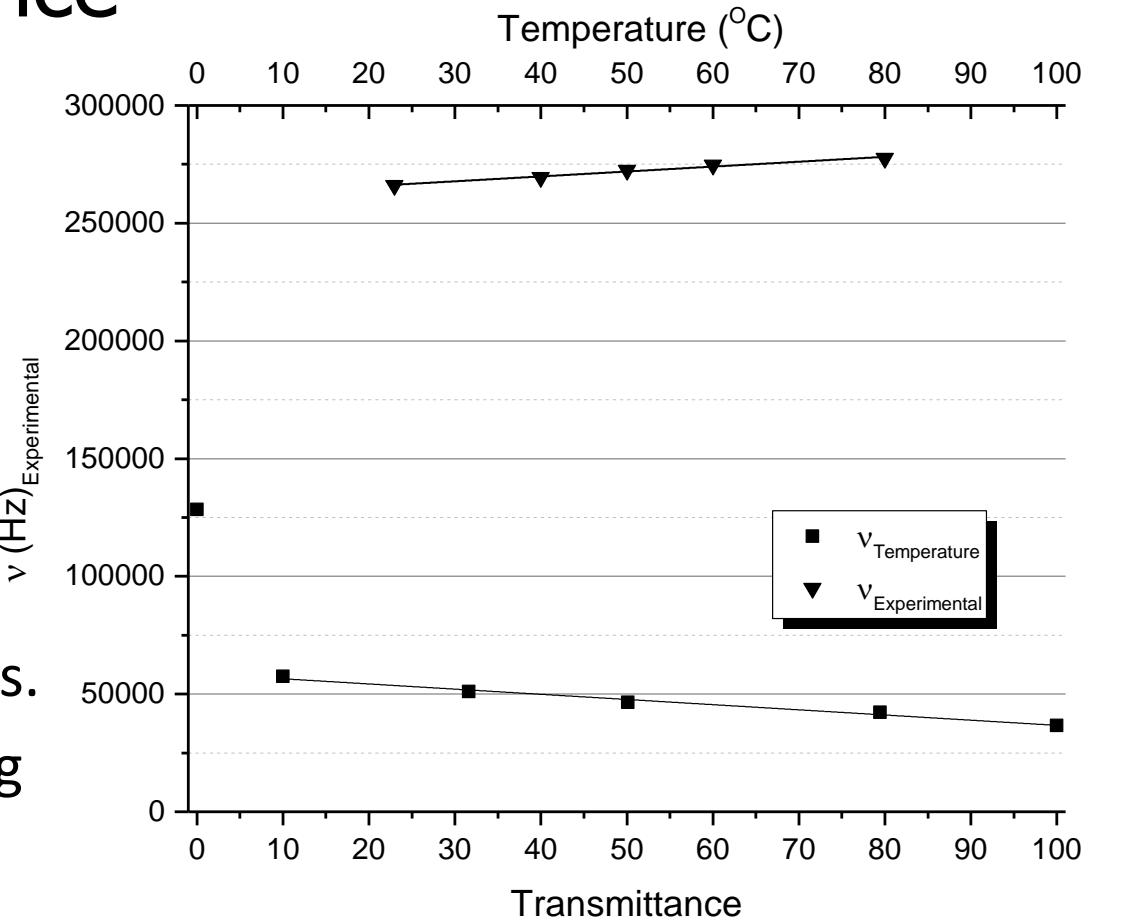
# Impedance Spectroscopy –REPRODUCIBLE!





# Temperature Dependence

- Mobility is highly dependant on temperature, T:
- $\mu_{(T,E)} = \mu_{(T,E=0)} e^{\gamma(T)\sqrt{E}}$
- From Graph:
  - As T increases,  $\nu$  increases.
  - As Light increases,  $\nu$  decreases.
- So heating of device not affecting results.



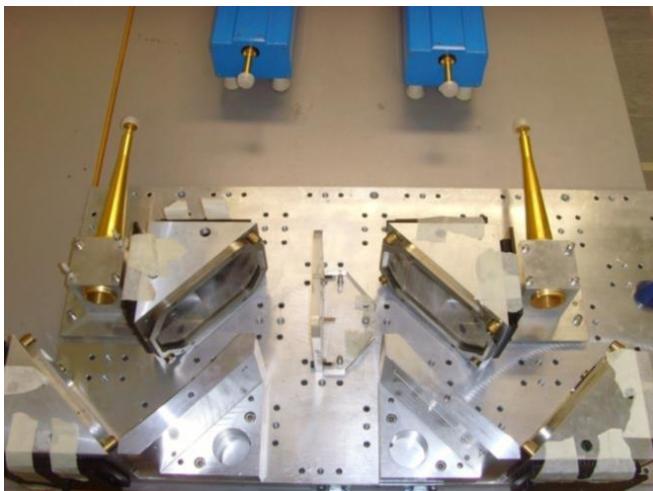
Left-bottom axis – Frequency resonance against % light (100% = 1234Wm<sup>-2</sup>)

Left-top axis – Frequency resonance against temperature.

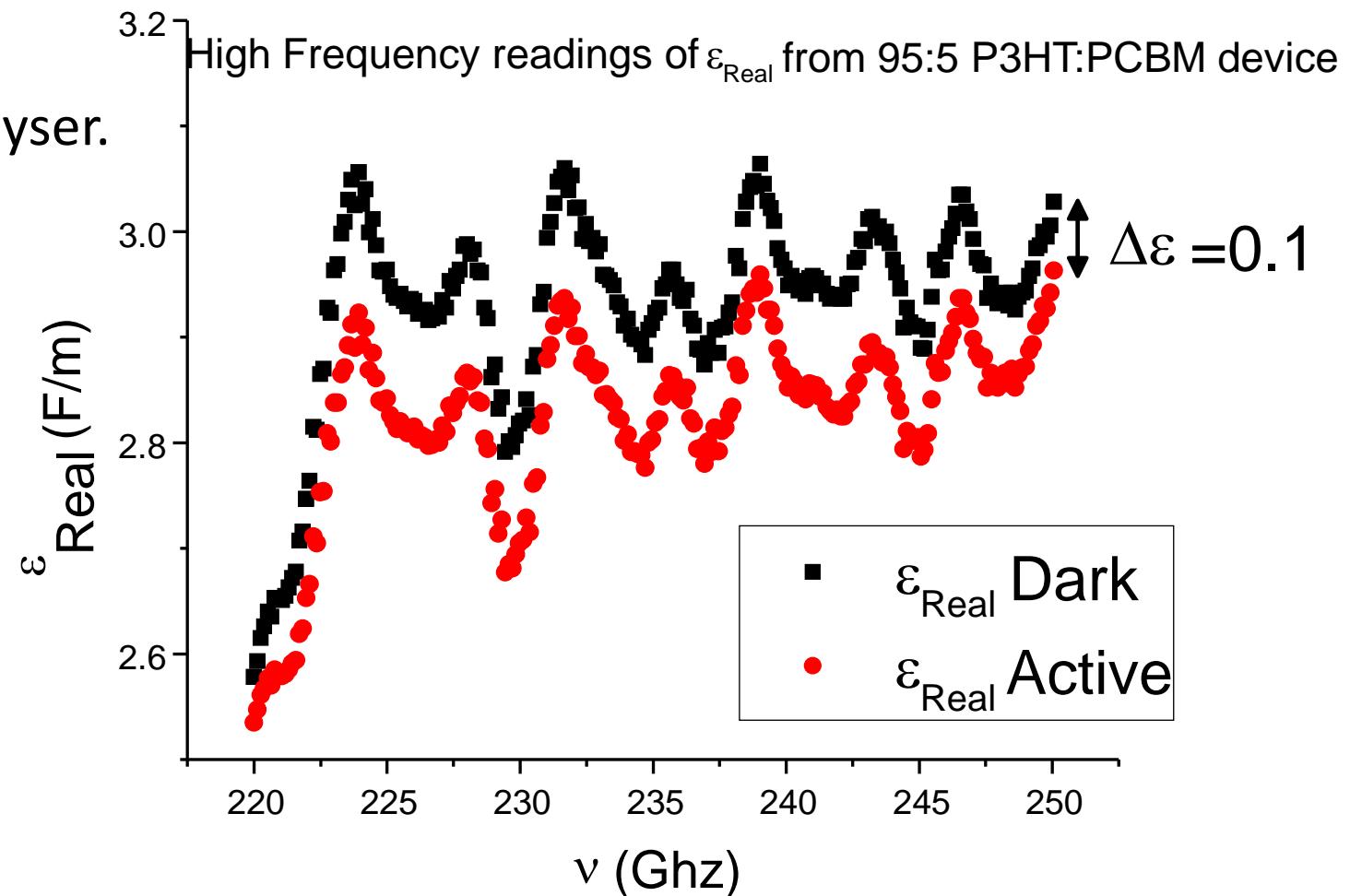


## $\Delta\epsilon_{Experimental} \rightarrow \Delta\epsilon_{GHz}$

- Can measure at GHz frequencies.
- Uses free space propagation on quasi-optical setup
  - mm-wave transition
  - Vector Network Analyser.



$\Delta\epsilon = 0.1$

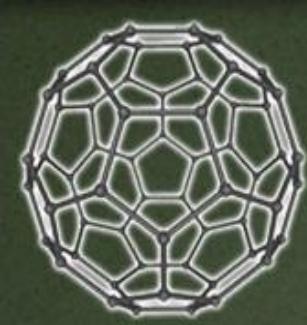




## $\Delta\epsilon_{Theory}$ vs $\Delta\epsilon_{Experimental}$

- $\Delta\epsilon_{Theory}$   
 $\Rightarrow \Delta\epsilon_{Plasma} = \Delta\epsilon_{(\mu, \Delta n)} \approx -10^{-9}$   
 $\Rightarrow \Delta\epsilon_{Space Charges} = \Delta\epsilon_{(\mu, G)} \approx 10^{-26}$   
 $\Rightarrow \Delta\epsilon_{e-h} = \Delta\epsilon_{(r_c, \Delta n_{e-h})} \leq +10^{+5}$
- $\Delta\epsilon_{Experimental}$   
 $\Rightarrow \Delta\epsilon_{(\nu=100kHz)} \quad Low \ light \ Intensity \approx -0.1$   
 $\Rightarrow \Delta\epsilon_{(\nu=100kHz)} \quad High \ light \ Intensity \approx +1$   
 $\Rightarrow \Delta\epsilon_{(\nu=100GHz)} \quad High \ light \ Intensity \approx -0.1$   
 $\Rightarrow |\Delta\epsilon|_{(\nu=100GHz)} \quad High \ light \ Intensity \approx 0.1$   
(from phase shift)





# Conclusions

- Can optically induce dielectric changes in P3HT:PCBM
- Can measure said changes:
- $\Delta\epsilon_{Exp} = \Delta\epsilon_{(v)}$



An ITO:P3HT:PCBM:Al device

$$\begin{aligned}\bullet \Delta\epsilon_{Theory} &\Rightarrow \Delta\epsilon_{Plasma} &= \Delta\epsilon_{(\mu, \Delta n)} &\times \\&\Rightarrow \Delta\epsilon_{Space\ Charges} &= \Delta\epsilon_{(\mu, G)} &\times \\&\Rightarrow \Delta\epsilon_{e-h} &= \Delta\epsilon_{(r_c, \Delta n)} &\checkmark\end{aligned}$$

- Only theoretical model that can explain dielectric change is that of static charges  $\Rightarrow$  e-h pairs

